

107714,998 SEARCH HISTORY 7/18/05 RRA

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	334996	(fills or fill or filled or cover or covered or covers) near3 (hole or via or space)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:12
L2	168878	photoresist or (resist adj composition) or (photosensitive adj composition)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:13
L3	13831	1 and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:13
L4	11549	negative adj (photoresist or resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:47
L5	833	3 and 4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:14
L6	6148	(crosslink\$3 or cross-link\$3) near3 (hole or via or space)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 18:19
L7	34	5 and 6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:40
L8	55980	haloalkyl or haloalkylation	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:40

L9	10	7 not 8	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:40
L10	9	(remove or removing) adj (crosslink\$3 or cross-link\$3) near5 (hole or via or space)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:46
L11	0	(negative adj (photoresist or resist)) near10 (sidewall adj spacer)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:47
L12	9	(negative adj (photoresist or resist)) same (sidewall adj spacer)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:47
L13	0	(crosslink\$3 or cross-link\$3) adj plug	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 18:19
L14	14	(crosslink\$3 or cross-link\$3) adj plug	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 18:19

Inv. Name search 10/7/4, 998

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	28076	ho.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 20:07
L2	11549	negative adj (photoresist or resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 20:07
L3	89	1 and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 20:10
L4	373009	ho, jin.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 20:11
L5	998	ho-j\$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 20:11
L6	83	3 not 5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 20:12
L7	282	ho-b\$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 20:12
L8	11	6 and 7	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 20:12

